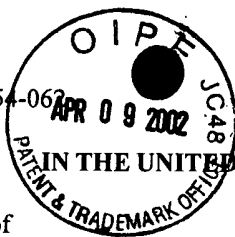


Docket No.: 57454-062



PATENT

In re Application of

Tomohide TERASHIMA

Serial No.: 09/834,954

Filed: April 16, 2001

For: SEMICONDUCTOR DEVICE

Group Art Unit: 2826

Examiner: Johannes P. Mondt

THE COMMISSIONER FOR PATENTS AND TRADEMARKS  
Washington, DC 20231

Dear Sir:

Transmitted herewith is an Amendment in the above identified application.

- ☒ No additional fee is required.  
☐ Applicant is entitled to small entity status under 37 CFR 1.27  
☐ Also attached:

The fee has been calculated as shown below:

	NO. OF CLAIMS	HIGHEST PREVIOUSLY PAID FOR	EXTRA CLAIMS	RATE	FEE
Total Claims	12	20	0	\$18.00 =	\$0.00
Independent Claims	2	3	0	\$84.00 =	\$0.00
Multiple claims newly presented					\$0.00
Fee for extension of time					\$0.00
Total of Above Calculations					\$0.00

- ☐ Please charge my Deposit Account No. 500417 in the amount of \$0.00. An additional copy of this transmittal sheet is submitted herewith.
- ☒ The Commissioner is hereby authorized to charge payment of any fees associated with this communication or credit any overpayment, to Deposit Account No. 500417, including any filing fees under 37 CFR 1.16 for presentation of extra claims and any patent application processing fees under 37 CFR 1.17.

Respectfully submitted,

MCDERMOTT, WILL & EMERY

Scott D. Paul  
Registration No. 42,984

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Date: April 9, 2002

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Docket No.: 57454-062

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Tomohide TERASHIMA

Application No.: 09/834,954 ✓

Filed: April 16, 2001 ✓

For: SEMICONDUCTOR DEVICE

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Group Art Unit: 2826

Examiner: J. Mondt

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AMENDMENT

Box Non-Fee Amendment  
The Commissioner for Patents and Trademarks  
Washington, DC 20231

Sir:

The following Amendment and Remarks are submitted in response to the Office Action dated January 9, 2002. Please amend the above-identified application as follows:

IN THE CLAIMS:

Sub B1  
A1

1. (Amended) A semiconductor device including:
- a semiconductor substrate having a main surface;
  - a semiconductor layer of a first conductive type which is formed on the main surface of said semiconductor substrate;
  - a first buried impurity region of the first conductive type formed between said semiconductor layer and said semiconductor substrate;